

Amendments to the Claims

This listing of claims will replace all prior versions, and listings of claims in the application:

Listing of Claims:

Claim 1 (Currently Amended): A phase contrast system for synthesizing an output electromagnetic field $u(x'', y'', z'')$, comprising:

a first phase modifying element for phase modulation of an input electromagnetic field by phasor values $e^{i\phi(x,y)}$,

first Fourier or Fresnel optics₁ for Fourier or Fresnel transforming the phase modulated electromagnetic field₁ positioned in ~~[[the]]~~ a propagation path of the phase modulated electromagnetic field,

a spatial filter for filtering the Fourier or Fresnel transformed electromagnetic field radiation by₁

in a region of spatial frequencies comprising DC in ~~[[the]]~~ a Fourier or Fresnel plane₁

phase shifting with a predetermined phase shift value θ the Fourier or Fresnel transformed ~~modulated~~ electromagnetic field in relation to ~~[[the]]~~ a

remaining part of the Fourier or Fresnel transformed electromagnetic radiation field, and

multiplying ~~[[the]]~~ an amplitude of the phase shifted transformed modulated electromagnetic radiation field with a constant B , and

in a region of remaining spatial frequencies in the Fourier or Fresnel plane,

multiplying an ~~[[the]]~~ amplitude of the Fourier or Fresnel transformed modulated electromagnetic radiation field with a constant A ,

second Fourier or Fresnel optics, for forming an electromagnetic field $o(x', y')$ by Fourier or Fresnel transforming the ~~phase shifted Fourier or Fresnel transformed~~ filtered electromagnetic field, and

a second phase modifying element for phase modulating the electromagnetic field $o(x', y')$ into an ~~[[the]]~~ electromagnetic field $o(x', y')e^{i\psi(x', y')}$ propagating as the desired output electromagnetic field $u(x'', y'', z'')$.

Claim 2 (Original): A phase contrast system according to claim 1, wherein at least one of the first and second phase modifying elements is further adapted for phase

modulation by first phasor values for a first polarization and second phasor values for a second orthogonal polarization of the input electromagnetic field.

Claim 3 (Currently Amended): A phase contrast system according to claim 2, wherein the second phase modifying element is further adapted for phase modulation by the first phasor values $e^{i\psi_1(x', y')}$ for [[a]] the first polarization and the second phasor values $e^{i\psi_2(x', y')}$ for [[a]] the second orthogonal polarization of the input electromagnetic field.

Claim 4 (Currently Amended): A phase contrast system according to claim 3 [[2]], further comprising an element for directing the phase modulated modified orthogonal electromagnetic fields into separate paths of propagation, [[e.g.]] to be applied in a non-interfering counter-propagating geometry.

Claim 5 (Previously Presented): A phase contrast system according to claim 1, wherein

$$A = 1.$$

Claim 6 (Previously Presented): A phase contrast system according to claim 1, wherein

$$B = 1.$$

Claim 7 (Previously Presented): A phase contrast system according to claim 1, wherein

$$\theta = \pi.$$

Claim 8 (Currently Amended): A phase contrast system according to claim 1, wherein the phasor values $e^{i\phi(x,y)}$ of the first phase modifying element and the phase shift value θ substantially fulfil that

$$o(x', y') \cong A \left[\exp(i\tilde{\phi}(x', y')) + K \overline{\alpha} \left(BA^{-1} \exp(i\theta) - 1 \right) \right]$$

wherein

A is an optional amplitude modulation of the spatial [[phase]] filter outside [[the]] a zero-order diffraction region,

B is an optional amplitude modulation of the spatial [[phase]] filter in the zero-order diffraction region,

$\overline{\alpha} = \overline{|\alpha|} \exp(i\phi_{\overline{\alpha}})$ is [[the]] an average of the phasors phasor values $e^{i\phi(x,y)}$ of [[the]]

resolution elements of the first phase modifying element, and

$$\tilde{\phi} = \phi - \phi_{\alpha}, \text{ and}$$

$$K = 1 - J_0(1.22\pi\eta), \text{ wherein}$$

J_0 is ~~[[the]]~~ a zero-order Bessel function and

η relates ~~[[the]]~~ a radius R_1 of ~~[[the]]~~ a zero-order filtering region to ~~[[the]]~~ a radius R_2 of ~~[[the]]~~ a main-lobe of ~~[[the]]~~ an Airy function of ~~[[the]]~~ an input aperture,

$$\eta = R_1 / R_2 = (0.61)^{-1} \Delta r \Delta f_r,$$

wherein Δr is a radius of a circular input aperture and Δf_r is a spatial frequency range.

Claim 9 (Currently Amended): A phase contrast system according to claim ~~[[1]]~~ 8,
wherein the phase shift value θ substantially fulfills the equation

$$K|\bar{\alpha}| = \frac{1}{2|\sin \theta / 2|}.$$

Claim 10 (Currently Amended): A phase contrast system according to claim 1, wherein
at least one of the first and second phase modifying element elements comprises a

complex spatial electromagnetic field modulator that is positioned in ~~[[the]]~~ a path of the input electromagnetic field and comprises modulator resolution elements (x_m, y_m) , each ~~of the~~ modulator resolution ~~element~~ elements (x_m, y_m) modulating ~~[[the]]~~ a phase and ~~[[the]]~~ an amplitude of the electromagnetic field incident ~~upon it~~ thereon with a predetermined complex value $a_m(x_m, y_m)e^{i\phi(x_m, y_m)}$.

Claim 11 (Previously Presented): A phase contrast system according to claim 1, further comprising a light source for emission of the input electromagnetic field, the light source comprising a laser array, such as a VCSEL array.

Claim 12 (Previously Presented): An optical micro-manipulation or multi-beam optical tweezer system including the phase contrast system of claim 1.

Claim 13 (Previously Presented): A laser machining tool including the phase contrast system of claim 1.

Claim 14 (Currently Amended): A method of synthesizing an output electromagnetic

field $u(x'', y'', z'')$, comprising:

phase modulating an input electromagnetic field by phasor values $e^{i\phi(x,y)}$,

Fourier or Fresnel transforming the phase modulated electromagnetic field,

filtering the Fourier or Fresnel transformed electromagnetic field radiation by,

in a region of spatial frequencies comprising DC in ~~[[the]]~~ a Fourier or
Fresnel plane,

phase shifting with a predetermined phase shift value θ the Fourier or
Fresnel transformed modulated electromagnetic field radiation in relation
to ~~[[the]]~~ a remaining part of the Fourier or Fresnel transformed
electromagnetic field radiation, and

multiplying an ~~[[the]]~~ amplitude of the phase shifted transformed
~~modulated electromagnetic field radiation~~ with a constant B , and

in a region of remaining spatial frequencies in the Fourier or Fresnel
plane,

multiplying ~~[[the]]~~ an amplitude of the Fourier or Fresnel transformed
~~modulated electromagnetic field radiation~~ with a constant A ,

forming an electromagnetic field $o(x', y')$ by Fourier or Fresnel transforming the

phase shifted Fourier or Fresnel transformed filtered electromagnetic field, and

phase modulating the electromagnetic field $o(x', y')$ into the output an electromagnetic field $e(x', y')e^{i\psi(x', y')}$ $o(x', y')e^{i\psi(x', y')}$ propagating as the desired output electromagnetic field $u(x'', y'', z'')$.

Claim 15 (Currently Amended): A method according to claim 14, further comprising:

dividing the electromagnetic field $o(x', y')$ into pixels in accordance with [[the]] disposition of resolution elements (x, y) of a first phase modifying element having a plurality of individual resolution elements (x, y) , each resolution element (x, y) modulating [[the]] a phase of electromagnetic radiation incident ~~upon it~~ thereon with a predetermined phasor value $e^{i\phi(x, y)}$,

calculating the phasor values $e^{i\phi(x, y)}$ of the phase modifying element and the phase shift value θ substantially in accordance with

$$o(x', y') \cong A \left[\exp(i\tilde{\phi}(x', y')) + K |\alpha| (BA^{-1} \exp(i\theta) - 1) \right]$$

wherein

A is an optional amplitude modulation of [[the]] a spatial phase filter outside [[the]] a

zero-order diffraction region,

B is an optional amplitude modulation of the spatial phase filter in the zero-order diffraction region,

$\bar{\alpha} = |\bar{\alpha}| \exp(i\phi_{\alpha})$ is ~~the~~ an average of the phasors $e^{i\phi(x,y)}$ of the resolution elements of the phase modifying element, and

$\tilde{\phi} = \phi - \phi_{\alpha}$, and

$K = 1 - J_0(1.22\pi\eta)$, wherein

J_0 is ~~the~~ a zero-order Bessel function, and

η relates ~~the~~ a radius R_1 of ~~the~~ a zero-order filtering region to ~~the~~ a radius R_2 of ~~the~~ a main-lobe of ~~the~~ an Airy function of the input aperture,

$\eta = R_1 / R_2 = (0.61)^{-1} \Delta r \Delta f_r$,

wherein Δr is a radius of a circular input aperture and Δf_r is a spatial frequency range,

selecting, for each resolution element, one of two phasor values which represent a particular grey level, and

supplying the selected phasor values $e^{i\phi(x,y)}$ to the respective resolution elements

(x, y) of the first phase modifying element, and

supplying selected phasor values $e^{i\psi(x',y')}$ to respective resolution elements (x', y') of a second phase modifying element having a plurality of individual resolution elements (x', y'), each resolution element (x', y') modulating ~~[[the]]~~ a phase of electromagnetic radiation incident ~~upon it~~ thereon with the respective phasor value $e^{i\psi(x',y')}$ for generation of the output field $o(x', y')e^{i\psi(x', y')}$.